Application/Control No. 10/065,750 Applicant(s)/Patent Under Reexamination LIU ET AL. Examiner Chuong A Luu Art Unit Page 1 of 1

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NON-PATENT DOCUMENTS

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYYY format are publication dates. Classifications may be US or foreign.